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- 3 (("5563238") or ("3811931") or ("3676401")).PN.  - 1862 (resist or photoresist or photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7) with (lactic or ketone or bexamethyldisilazane or HMDS) ((resist or photoresist or photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7) with (lactic or ketone or photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7) with (lactic or ketone or or ganometal\$3 or metal adj salt or photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7) with (lactic or ketone or organometal\$3 or metal adj salt or siloxane or silane or hexamethyldisilazane or HMDS)) and (semiconduct\$3 or semi adj conduct\$3 or wafer or silicon or "Si") same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7)  - 397 (((resist or photoresist or photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7)  USPAT; USPAT; 2003/06/28 photopolymer\$7) same (coupl\$3 or bond\$3 or prim\$3 or adhes\$7)  USPAT; 1003/06/28 photopolymer\$7) same (coupl\$3 or bond\$3 or bond\$3 or prim\$3 or adhes\$7)
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- 397 (((resist or photoresist or photopolymer\$7) same (coupl\$3 or bond\$3 US-PGPUB; 15:47
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prim\$3 or adhes\$7)) and (430/311,319,327-329).ccls.)  ((light) near3 (degrad\$4) near3 (prim\$3 USPAT; or adhes\$7) same (resist or photoresist)) US-PGPUB; EPO; JPO; IBM_TDB		[	fragment\$4) same (coupl\$3 or bond\$3 or		
- 0 (430/311,319,327-329).ccls.) ((light) near3 (degrad\$4) near3 (prim\$3 USPAT; US-PGPUB; EPO; JPO; IBM_TDB		i			
- 0 ((light) near3 (degrad\$4) near3 (prim\$3 USPAT; 2003/07/09 or adhes\$7) same (resist or photoresist)) US-PGPUB; EPO; JPO; IBM_TDB					
or adhes\$7) same (resist or photoresist)) US-PGPUB; 12:40 EPO; JPO; IBM_TDB	_	0	((light) near3 (degrad\$4) near3 (prim\$3	USPAT;	2003/07/09
EPO; JPO; IBM_TDB	1		or adhes\$7) same (resist or photoresist))		1
IBM_TDB	1		, , , , , , , , , , , , , , , , , , , ,	· ·	
10 1/13 mbt) many /dominded) many /mmimes   HEDAM:   2002/07/16	1				
-   12 ((light) hears (degrad;4) hears (prim;5   USPAL;   2003/07/16	-	12		USPĀT;	2003/07/16
or adhes\$7) and (resist or photoresist)) US-PGPUB; 16:26		]	or adhes\$7) and (resist or photoresist))	1	16:26
EPO; JPO;		1			
IBM_TDB		]			
- 0 ((light) near3 (degrad\$4) with (primer or USPAT; 2003/07/09	[ -	0		· ·	1
priming) same (resist or photoresist)) US-PGPUB; 12:47		1	priming) same (resist or photoresist))		12:47
EPO; JPO;	1	1			
IBM_TDB		l		TRW_LDB	

_	88	((bilayer or bi adj layer) same positive	USPAT;	2003/07/16
		near2 (resist or photoresist))	US-PGPUB;	16:27
			EPO; JPO;	
			IBM_TDB	
-	74	(((bilayer or bi adj layer) same positive	USPAT;	2003/07/18
		near2 (resist or photoresist))) and	US-PGPUB;	13:13
		(thick or thickness) same (resist or	EPO; JPO;	
		photoresist)	IBM_TDB	
<del>-</del>	2	((hexamethyldisilazane or HMDS) near5	USPAT;	2003/07/18
		decompos\$4) same (resist or photoresist)	US-PGPUB;	14:06
		<u> </u>	EPO; JPO;	
			IBM TDB	
_	12	((hexamethyldisilazane or HMDS) near5	USPĀT;	2003/07/18
		(light or uv)) same (resist or	US-PGPUB;	15:43
		photoresist)	EPO; JPO;	1
			IBM_TDB	
_	92	(134/1.3).ccls. and (light or uv) same	USPAT;	2003/07/18
	•	(resist or photoresist)	US-PGPUB;	15:34
		, · · · · · · · · · · · · · · · · · · ·	EPO; JPO;	
			IBM TDB	
l <u></u>	6	((134/1.3).ccls. and (light or uv) same	USPAT;	2003/07/18
		(resist or photoresist)) and	US-PGPUB;	15:35
		(hexamethyldisilazane or HMDS)	EPO; JPO;	
		· -	IBM TDB	
_	17	((hexamethyldisilazane or HMDS) near5	USPĀT;	2003/07/18
		(light or uv or ultraviolet)) same	US-PGPUB;	16:03
		(resist or photoresist)	EPO; JPO;	
		· ·	IBM_TDB	
_	16		USPAT;	2003/07/18
		((bond\$3 or coupl\$3) near2 (strength or	US-PGPUB;	16:17
		energy)) same ((silicon or Si) near5	EPO; JPO;	
		(oxygen))	IBM_TDB	
-	19		USPAT;	2003/07/18
		((bond\$3 or coupl\$3) near2 (strength or	US-PGPUB;	16:18
		energy)) same ("Si0" or "OSi")	EPO; JPO;	
			IBM TDB	